## 5.3.2 Summary to: 5.3 Cleanrooms, Particles and Contamination

- Dirt in any form as "particles" on the surface of wafer, or as "contamination" inside the wafer is almost always deadly
  - Particles with sized not much smaller than minimum feature sizes (i.e. < 10 nm in 2007) will invariably cover structures and lead to local dysfunction of a transistor or whatever.
  - Point defects like metal atoms in the Si lattice may precipitate and cause local short circuits etc. from the "inside", killing transistors
  - One dysfunctional transistor out of 1.000.000.000 or so is enough to kill a chip!
- Being extremely clean is absolutely mandatory for high Yields Y.
  - Use cleanrooms and hyper-clean materials!
  - It won't be cheap!



